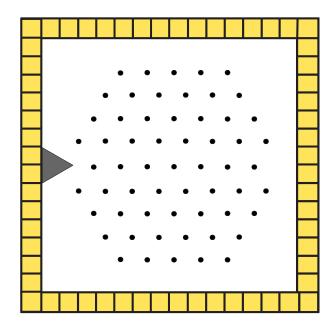
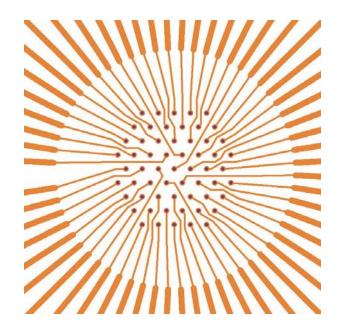
## HexaMEA40/10

HexaMEA40/10iR-ITO

### Hexa Microelectrode Array







multichannel\*

systems

### Technical Specifications HexaMEA40/10

Temperature compartibility Dimension (W x D x H)

Base material

Contact pads and track material

Electrode diameter

Interelectrode distance (centre to centre)

Electrode height Electrode type Isolation type

Electrode impedance Electrode layout grid Number of electrodes

Reference electrode

MC\_Rack:

Source layout in "Data Source Setup"

Channel map

MEA perfusion chamber

0 - 125 °C

49 mm x 49 mm x 1 mm

Glass

ITO (Indium tin oxide)

10 µm 40 µm Planar

TiN (Titanium nitride)

Silicon nitride 500 nm (PEVCD) Approximately 250 - 400  $k\Omega$ 

Hexagonal

60

with internal reference electrode (iR)

2 dim (MEA)

HexaMEA40/10.cmp

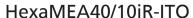
(w/o) Without ring

(gr) Glass ring: ID +/- 20 mm, OD 24 mm, height 6 / 12 mm

(pr) Plastic ring without thread: ID 26 mm, OD 30 mm, height 6 / 3 mm

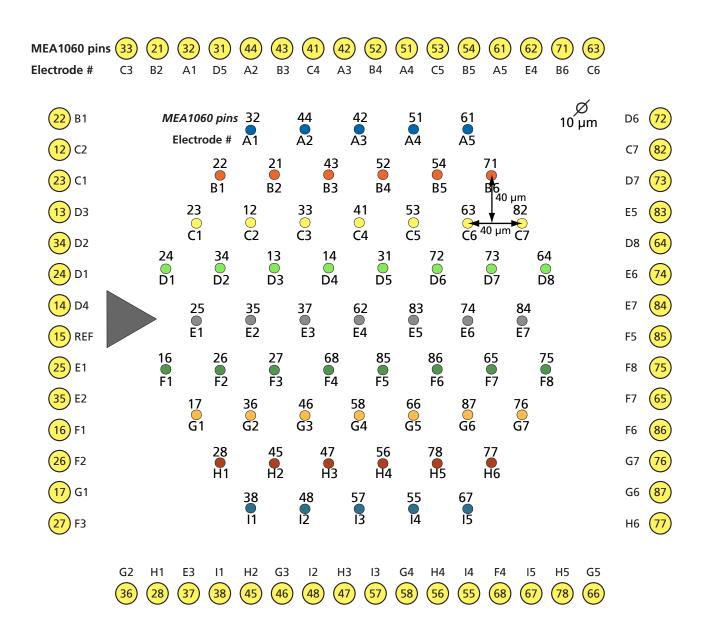
(pr-T) Plastic ring with thread: ID 25 mm, OD 30 mm, height 6 / 15 mm

# HexaMEA40/10





#### **Electrode Layout**



The letter-digit code is the electrode identifier and refers to the position of the electrode in the hexa grid. The specified MEA1060 amplifier pin numbers are the channel numbers that are used in MC\_Rack.